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""TECHNIQUES FOR MEASUREMENTS OF GAS PHASE SPECIES"";
""Information Resources""; ""Roles of the Database In Motivating
Diagnostic Experiments""; ""SURFACE REACTION DATABASE AND
DIAGNOSTICS""; ""Information Resources""; ""New Diagnostic
Techniques""; ""FINDINGS""
""REFERENCES""""4 Heterogeneous Processes ""; ""INTRODUCTION"";
""STATE OF THE DATABASE""; ""TECHNIQUES FOR IMPROVING THE
DATABASE""; ""Approach""; ""Measurements On Realistic Plasma
Reactors""; ""Incident Flux and Desorbing Flux Analysis""; ""Condition of
the Surface""; ""Technology""; ""Ultrahigh-Vacuum Approach Using
Mass and Energy Selected Reactive Beams""; ""Particle Beams"";
""Sticking Coefficients""; ""Synergistic Effects""; ""Substrate Temperature
Dependence""; ""Angle Dependence""; ""Computer Simulations"";
""FINDINGS""; ""REFERENCES""; ""5 Electron Collision Processes ""
""INTRODUCTION""""IONIZATION""; ""Atoms""; ""Molecules"";
""Theoretical Methods and Advances""; ""Neutral Dissociation"";
""ELECTRON-IMPACT EXCITATION""; ""ATTACHMENT""; ""MOMENTUM
TRANSFER, SWARM, AND DISCHARGE MEASUREMENTS""; ""GENERAL
COMMENTS""; ""FINDINGS""; ""REFERENCES""; ""6 Ion Processes, Neutral
Chemistry, And Thermochemical Data ""; ""INTRODUCTION""; ""CROSS
SECTIONS AND RATE COEFFICIENTS""; ""Ion Processes""; ""Momentum
Transfer""; ""Ion-Molecule and Charge Exchange Reactions""; ""Ion-Ion
Neutralization""; ""Electron-Ion Recombination""
""Ion-Neutral and Neutral-Neutral Excitation""""Neutral Chemistry"";
""Status of the Database""; ""Excited State Chemistry and Penning
Ionization""; ""Summary""; ""Ion Processes""; ""Neutral Chemistry"";
""THERMOCHEMICAL DATA""; ""FINDINGS""; ""REFERENCES""; ""Appendix
A: Acronyms and Abbreviations""; ""Appendix B: Workshop Agenda"";
""Appendix C: Workshop Participants""
